

What is claimed is:

1. A measuring apparatus comprising:

a measuring unit having a transparent dielectric block,  
a metal film formed on one of the surfaces of said dielectric  
5 block, and a transparent dielectric film formed on said metal  
film;

a light beam entering means for entering a light beam  
into said dielectric block at various incident angles within  
an angle range that satisfies the conditions of total reflection  
10 at the interface between said dielectric block and said metal  
film, and creates two or more dark lines due to attenuated total  
reflections in a light beam totally reflected at said interface;

a light detecting means for receiving said light beam  
totally reflected at said interface, and detecting positions  
15 on a light receiving surface of said two or more dark lines  
contained therein; and

a calculation means for calculating a variation in each  
of said positions of said two or more dark lines on said light  
receiving surface arising from a change in the dielectric  
20 constant of a substance placed on said transparent dielectric  
film with reference to one of said two or more dark lines having  
the least positional variation on said light receiving surface  
among said two or more dark lines, based on the output of said  
light detecting means.

25 2. A measuring apparatus according to claim 1, wherein  
said dark line having the least positional variation is a dark

line created by a light component of said light beam having the largest incident angle at said interface among said two or more dark lines.

3. A measuring apparatus according to claim 1, wherein  
5 said measuring unit further comprises a sensing material fixed on said dielectric film, and said change in the dielectric constant is a change in said dielectric constant arising from a reaction when a test substance containing a material that reacts to said sensing material is brought into contact with  
10 said sensing material.

4. A measuring apparatus according to claim 2, wherein said measuring unit further comprises a sensing material fixed on said dielectric film, and said change in the dielectric constant is a change in said dielectric constant arising from  
15 a reaction when a test substance containing a material that reacts to said sensing material is brought into contact with said sensing material.

5. A measuring apparatus according to claim 1, wherein said metal film has a thickness of 10 nm to 70 nm, and said  
20 transparent dielectric film has a thickness of 100 nm to 2000 nm.

6. A measuring apparatus according to claim 2, wherein said metal film has a thickness of 10 nm to 70 nm, and said transparent dielectric film has a thickness of 100 nm to 2000  
25 nm.

7. A measuring apparatus according to claim 3, wherein

said metal film has a thickness of 10 nm to 70 nm, and said transparent dielectric film has a thickness of 100 nm to 2000 nm.

8. A measuring apparatus according to claim 4, wherein  
5 said metal film has a thickness of 10 nm to 70 nm, and said transparent dielectric film has a thickness of 100 nm to 2000 nm.

9. A measuring apparatus according to claim 1, wherein  
said transparent dielectric film is made of  $\text{SiO}_2$ , a glass, or  
10 plastic material.

10. A measuring apparatus according to claim 2, wherein  
said transparent dielectric film is made of  $\text{SiO}_2$ , a glass, or  
plastic material.

11. A measuring apparatus according to claim 3, wherein  
15 said transparent dielectric film is made of  $\text{SiO}_2$ , a glass, or  
plastic material.

12. A measuring apparatus according to claim 4, wherein  
said transparent dielectric film is made of  $\text{SiO}_2$ , a glass, or  
plastic material.

20 13. A measuring apparatus according to claim 5, wherein  
said transparent dielectric film is made of  $\text{SiO}_2$ , a glass, or  
plastic material.

14. A measuring apparatus according to claim 6, wherein  
said transparent dielectric film is made of  $\text{SiO}_2$ , a glass, or  
25 plastic material.

15. A measuring apparatus according to claim 7, wherein

said transparent dielectric film is made of  $\text{SiO}_2$ , a glass, or plastic material.

16. A measuring apparatus according to claim 8, wherein said transparent dielectric film is made of  $\text{SiO}_2$ , a glass, or  
5 plastic material.